

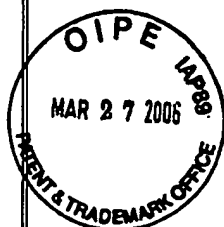
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(Use several sheets if necessary)

Applicant:

Gicquel, et al.

Filing Date:

July 11, 2005

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U.S. PATENT DOCUMENTS

Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date if Appropriate
KMS	1.	6,200,183 B1	March 13, 2001	Badzian, et al.	445	24	
KMS	2.	6,261,424 B1	July 17, 2001	Goncharenko, et al.	204	192.38	

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KMS	4.	0 635 584 A1	July 14, 1994	EP				
KMS	5.	WO 01/96633 A1	June 14, 2001	PCT				
KMS	6.	WO 01/96634 A1	June 14, 2001	PCT				

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KMS	8.	Gicquel, et al., <i>Materials Research</i> , 2003, Vol. 6, No. 1 pp. 25-37.
KMS	9.	Gordon, et al., <i>Journal of Applied Physics</i> , February 1, 2001, Vol. 89, No. 3, pp. 1544-1549.
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KMS	12.	Lombardi, et al., "Diagnostics and Modeling of Moderate Pressure Microwave H ₂ /CH ₄ Plasmas Obtained Under Pulsed Mode" paper, 2001.
KMS	13.	Silva, et al., <i>Diamond and Related Materials</i> , 1996, Vol. 5, pp. 338-344.

EXAMINER /Kelly Stouffer/

DATE CONSIDERED 07/28/2006

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